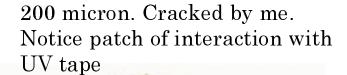
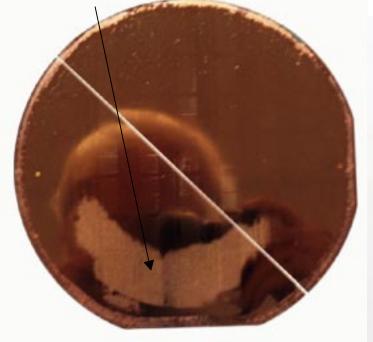
Thin IZM Wafers with Photoresist

150 micron. Region ground through to photoresist. Uneven coating?







250 micron. Large region of interaction with UV releasing tape.

Gilchriese - December 1999